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Electronic and magnetic properties of new half-metallic ferromagnetic rutile Ti_{1-x-} $_yV_xNi_yO_2$ (x=y=6.25%): A first-principles study

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ABSTRACT

We report electronic and magnetic properties of the new half-metallic ferromagnetic co-doped system of rutile $Ti_{1-x-y}V_xNi_yO_2$ (x=y=6.25%). The semiconductor ferromagnetic doped system of rutile $Ti_{1-x}V_xO_2$ (x=6.25%) system is revisited as the reference. The plane-wave GGA + U method was used after choosing U at Ti 3d site in the fully-optimized rutile TiO₂. The co-doped system exhibits the total magnetic moment of 1.41 μ_B/Ni atom localized at the V and Ni sites which is significantly higher than that of the doped system. Interestingly, the local ferrimagnetism centered at the cations of V^{4+} and V^{4+} and V^{4+} is found with the minor contribution from their nearest-neighboring V^{2-} ions bound via the V^{2-} hybridization. The V^{4+} ion induces the half-metallic behavior by introducing spin-up hole V^{4-} and V^{4-

Keywords: electronic properties; magnetic properties; rutile TiO2; half-metallic ferromagnetic

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